

Abstracts

Millimeter Resonance Isolator Using Chemically Deposited Ferrite Films (Correspondence)

W. Wade, Jr., T. Collins and R. Stern. "Millimeter Resonance Isolator Using Chemically Deposited Ferrite Films (Correspondence)." 1962 Transactions on Microwave Theory and Techniques 10.6 (Nov. 1962 [T-MTT]): 611-611.

An experimental resonance isolator showing the feasibility of newly developed chemically deposited ferrite films, was made in the 35-Gc region. Included in this letter are two graphs showing the isolation characteristics that were obtained and also a brief description of the film preparation techniques.

[Return to main document.](#)